

ABSTRACT

An object of the present invention is to provide a ceramic heater for a semiconductor producing/examining device having
 5 a resistance heating element superior in adhesion to a substrate, and the ceramic heater for a semiconductor producing/examining device of the present invention is a ceramic heater for a semiconductor producing/examining device including: a ceramic substrate; and a resistance heating element formed on the surface
 10 of the ceramic substrate, wherein irregularities are formed on the side face of the resistance heating element.